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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.		
09/939,651 08/28/2001		Li Li	M4065.0159/P159-B	5524		
24998	7590 04/24/2003					
DICKSTEIN SHAPIRO MORIN & OSHINSKY LLP			EXAMINER			
	2101 L STREET NW WASHINGTON, DC 20037-1526			TRAN, BINH X		
	_		ART UNIT	PAPER NUMBER		
			1765			
			DATE MAILED: 04/24/2003	•		

Please find below and/or attached an Office communication concerning this application or proceeding.

- _V s			L		
	Application No.	pplicant(s))		
	09/939,651	LI ET AL.	l		
Offic Action Summary	Examiner	Art Unit	<u> </u>		
	Binh X Tran	1765			
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet	t with the correspondence a	ddress		
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a repl - If NO period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply with, by statute - Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1,704(b). Status	36(a). In no event, however, may y within the statutory minimum of will apply and will expire SIX (6) No. a cause the application to become	y a reply be timely filed thirty (30) days will be considered tim MONTHS from the mailing date of this BABANDONED (35 U.S.C. & 133).	ely. communication		
1) Responsive to communication(s) filed on 10 A	<u> April 2003</u> .				
2a) ☐ This action is FINAL . 2b) ☑ Th	is action is non-final.				
Since this application is in condition for allowed closed in accordance with the practice under Disposition of Claims	ance except for formal r Ex parte Quayle, 1935	natters, prosecution as to t C.D. 11, 453 O.G. 213.	he merits is		
<u> </u>	ion				
4) ☐ Claim(s) <u>92-108</u> is/are pending in the applicat4a) Of the above claim(s) is/are withdraw					
_	wn from consideration.				
5) Claim(s) is/are allowed.					
6) Claim(s) 92-108 is/are rejected.					
7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/o	r alastian requirement				
Application Papers	r election requirement.				
9) The specification is objected to by the Examine	r. '				
10)☐ The drawing(s) filed on is/are: a)☐ accept	oted or b) objected to b	y the Examiner.			
Applicant may not request that any objection to the		•			
11) The proposed drawing correction filed on		disapproved by the Examir	ner.		
If approved, corrected drawings are required in rep					
12) The oath or declaration is objected to by the Ex	aminer.				
Priority under 35 U.S.C. §§ 119 and 120					
13) Acknowledgment is made of a claim for foreign	n priority under 35 U.S.C	C. § 119(a)-(d) or (f).	•		
a) ☐ All b) ☐ Some * c) ☐ None of:					
1. Certified copies of the priority documents					
2. Certified copies of the priority documents					
 3. Copies of the certified copies of the prior application from the International But * See the attached detailed Office action for a list 	reau (PCT Rule 17.2(a)).	Stage		
14) Acknowledgment is made of a claim for domestic	· · · · · · · · · · · · · · · · · · ·		al application).		
a) ☐ The translation of the foreign language pro 15)☐ Acknowledgment is made of a claim for domesti	visional application has	been received.	.,		
Attachment(s)	o phony under 50 0.0.	C. 33 120 allulul 121.			
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice	ew Summary (PTO-413) Paper No of Informal Patent Application (PT			

Application/Control Number: 09/939,651

Art Unit: 1765

DETAILED ACTION

Double Patenting

1. The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. See *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970);and, *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent is shown to be commonly owned with this application. See 37 CFR 1.130(b).

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

2. Claims 92-108 are rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 1-19 of U.S. Patent No. 6,335,292 in view of Yang et al. 6,426,016. The instant claims differ from the claims of US 6,335,292 by further specify that the oxide layer is formed over the substrate and the oxide layer is contact with the plasma etching gas. The step of forming the oxide layer over the substrate and exposing it to the plasma etching gas is very well know in the semiconductor art. In a semiconductor method, Yang discloses that the oxide layer (230) is formed over the substrate and it is in contact with the plasma etching gas. It would have been obvious to one having ordinary skill in the art, at the time of the invention, to modify US 6,335,292 in view of Yang by forming an oxide layer over the

Application/Control Number: 09/939,651

Art Unit: 1765

substrate and expose it to the plasma etching gas because the oxide layer will help to an insulating layer to protect the substrate.

3. The following table will compare the claims between US 6,335,292 and present application (09/939,651).

US 6,335,292 Claims	Present application (09/939,651) Claims
1	92
2	93
3	94
4	95
5	96
6	97
7	98
8	99
9	100
10	101
11	102
12	103
13	104
14	105
15	106
18	107
19	108

Application/Control Number: 09/939,651

Art Unit: 1765

Response to Arguments

Applicant's arguments with respect to claims 92-108 have been considered but 4.

are moot in view of the new ground(s) of rejection.

Conclusion

5. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Binh X Tran whose telephone number is (703) 308-

1867. The examiner can normally be reached on Monday-Thursday and every other

Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Benjamin L Utech can be reached on (703) 308-3836. The fax phone

numbers for the organization where this application or proceeding is assigned are (703)

872-9310 for regular communications and (703) 872-9311 for After Final

communications.

Any inquiry of a general nature or relating to the status of this application or

proceeding should be directed to the receptionist whose telephone number is (703) 308-

0661.

Binh X. Tran

April 22, 2003

moho BENJAMIN L. UTECH SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 1700

Page 4